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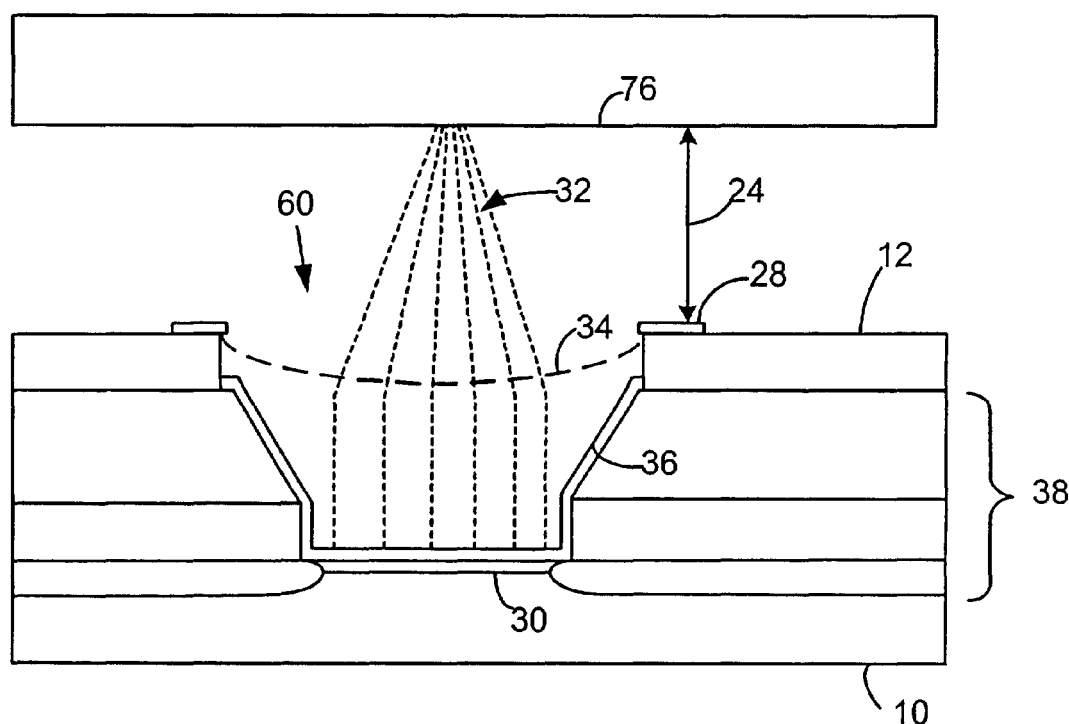
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(54) Title: INTEGRATED FOCUSING EMITTER



(57) Abstract: A method for creating an electron lens (28) includes the steps of applying a polymer layer (12) on an emitter surface (36) of an electron emitter (60) and then curing the polymer layer (12) to reduce volatile content.



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